

HIZB Andt.

M. Brunson

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PATENT

Customer No. 22,852

Attorney Docket No. 04329.2222

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	AUG
Kouji MATSUO, et al.	Group Art Unit: 2814
Serial No.: 09/492,780	Examiner: Rao, Shrinivas H.
Filed: January 28, 2000	2800
For: SEMICONDUCTOR DEVICE AND METHOD OF MANUFACTURING THE SAME	·))
Assistant Commissioner for Patents Washington, DC 20231	

AMENDMENT

In reply to the Final Office Action of May 31, 2002, and in support of the RCE filed concurrently herewith, please amend the application as follows:

IN THE CLAIMS:

Sir:

Please amend claim 12 as follows:

12. (Twice Amended) A semiconductor device, comprising:

a semiconductor substrate;

a metal-containing insulating film formed directly or indirectly on said semiconductor substrate, said metal-containing insulating film including a plurality of first insulating regions each of which is formed of a grain containing a metal oxide and a second insulating region, said second insulating region formed of an amorphous insulating material; and

an electrode formed on said metal-containing insulating film.

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